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A novel method to produce carbon nanotubes using EDM process

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ABSTRACT

Carbon nanotubes (CNTs) have been used in various fields of research due to their unique properties. There are various methods such as arc discharge, laser ablation, chemical vapor deposition (CVD), template-directed synthesis and the use of the growth of CNTs in the presence of catalyst particles. Special ambient gas is required for the fabrication of CNTs, in order to prevent the oxidation of carbon at high temperature. In this study, we developed a simple, fast and low cost method in which CNTs can be fabrication by single-pulse discharge with low energy in air. The single-pulse discharge system was designed to adjust the peak current and pulse duration. A graphite rod electrode generated an electric arc between electrode and the substrate at a distance of 1 µm. A promising result was obtained by using single-pulse discharge with a pulse duration of 1000 µs and peak current of 2.5 A; that is, many CNTs grew on the substrate under these conditions. This method can overcome the limitations of the special ambient gas and enable the fabrication of CNTs at a selected location on the substrate.

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1. Introduction

Since the development of carbon nanotubes (CNTs) in 1991 [1], there has been considerable interest in CNTs with unique properties. Due to the unique mechanical, electrical and chemical properties of nanometer-scale tubular forms of CNTs [2,3], they have been considered as important components of numerous microscale and/or nanoscale sensors [4-6] and also used in many nanoscale applications. Various methods have been used for growing CNTs in the presence of catalyst particles. The principal methods for producing CNTs are arc discharge method [7-10], chemical vapor deposition (CVD) method [11,12] and laser ablation [13]. The CVD method is extremely suitable for batch production of CNTs: however, this method usually requires the predeposition of a catalyst layer on a suitable substrate and preheats the substrate to a high temperature of 500-1300 °C. For producing CNTs at a selected location, CVD requires some complicated procedures such as etching, deposition and masking. In the arc discharge process, CNTs are easily produced at a location that is in the front of the electrode containing carbon. This method can deposit CNTs at the selected location without any mask. However, the arc discharge method usually requires a vacuum environment and special ambient gas (helium or hydrogen) to produce multiwalled CNTs. The laser ablation method is similar to the arc discharge method, but it uses an expensive high-energy laser instead of the arc discharge to heat the graphite catalyst. The vaporized graphite is suddenly cooled to grow CNTs. Some ambient gas and high temperature are also required for the growth of CNTs; however, the production rate of this method is low.

A simple process for fabricating CNTs at a selected location will be beneficial to the development of nanoelectronic devices and biological probes. As for CVD method, a usual and common method to produce CNTs, its environment has serious requirement and its leadtime is longer. The arc discharge method has attracted attention due to its easy operation and ability to produce CNTs at a selected location. Sugai et al. [7] have grown singlewalled CNTs by utilizing pulsed arc discharge (22 A at a duration of more than 1 ms) in helium or hydrogen gas at an atmospheric pressure of 500T and a temperature of 1000 °C. Takikawa et al. [14] have used a continuous arc torch to produce CNTs. Recently, Parkansky et al. [15] have utilized a few short-pulsed arc discharges (7–100 A, 0.2–20 μ s) in ambient air in order to produce multiwalled nanotubes at room temperature.

In order to overcome the limitation of conventional technology, we attempted to develop a simple, fast and low cost method to produce CNTs. We used a short single pulse to generate arc discharge in air at room temperature. The graphite electrode can be moved to selected locations on the substrate. After numerous pulses of arc discharge, CNTs will be produced on substrate under simple environment without vacuum and special ambient gas.

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2. Experimental

2.1. Substrate and electrode

The structure, quality and quantity of CNTs are dependent on its production method and catalyst particles. Catalyst particle are the decisive factors for the formation of CNTs, including the type, grain size and concentration of a catalyst. Elements such as Fe, Co, Ni or Cu are commonly used as catalysts. In addition, La, Y element as catalyst also shows a good result. In this study, we used Fe, which is one of the most common types of catalyst, and precoated it on a substrate by plasma sputtering equipment; this sputtering apparatus is shown in Fig. 1. The graphite substrate was cut into an appropriate size and its surface was polished in order to improve the surface roughness. The electrode material was also selected as graphite to obtain a sufficiently large number of carbon atoms. The physical properties of graphite are listed in Table 1.

2.2. Experimental equipment and process

The general arc discharge method requires a constant peak current of above 50 A for several minutes; hence, it requires special gas to prevent the oxidation or burning of carbon. In our mind, if discharge energy was reduced but the pulse energy intensity was still enough, it is possible to avoid high-temperature oxidation. Therefore, we attempted to produce CNTs under an atmosphere utilizing single-pulse discharge with a low peak current and short-pulse duration. The peak current (Ip) and pulse duration (Td) are regarded as the main parameters in this study. During single discharge, a semispherical-like point with a diameter range from 70 to 90 µm and depth from 25 to 30 µs is formed on the substrate and it just offers a collection of carbon molecule as a result in CNT growth. For this reason, discharge current and pulse duration are the most important parameters with concern of low or high energy. After numerous experiments and adjustment of parameter range, the influence of discharge energy on CNT growth is found. Table 2 shows the experimental parameters.

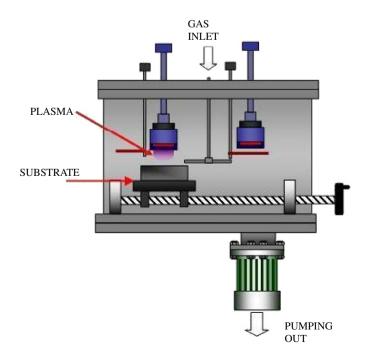


Fig. 1. Schematic representation of plasma sputtering apparatus.

Table 1

Physical properties of graphite

Apparent density (g/cm ³)	1.8
Compressive strength (kg/cm ²)	950
Thermal conductivity (kcal/m h °C)	100
Electric resistance ($\mu\Omega$ cm)	1200
Graphite purity (%)	99.99

Table 2

Experimental parameters

Electrode material	Graphite
Substrate	Graphite with Fe coated
Peak current (Ip)	2, 2.5 A
Pulse duration (Td)	800, 1000, 1300 μs
Times of pulse discharge	4
Discharge gap	1 µm

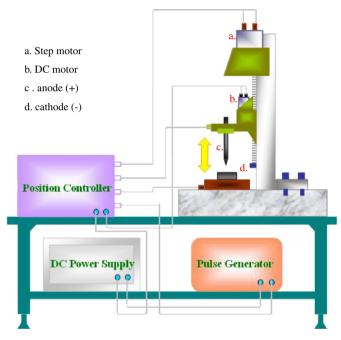


Fig. 2. Schematic representation of prototype microelectric discharge apparatus.

All experiments were carried out using a microelectric discharge machine with single-pulse discharge circuit, which was completely set up by us. A rod with a diameter of 5 mm and a conical angle of 60° was used as an electrode. As shown in Fig. 2, a graphite electrode and a substrate were connected to the anode and cathode, respectively. Using stepping motor in the direction of *Z*-axis was to control the appropriate gap of 1 µm between the electrode and the substrate. Single-pulse discharge was generated by a transistor circuit designed with adjustable peak current and pulse duration. Fig. 3 shows the schematic representation of the discharge circuit. The resulting CNTs were examined by scanning electron microscopy (SEM) and transmission electron microscopy (TEM) in order to observe the quality and characteristics of the CNTs.

3. Experimental results and discussions

3.1. Conditions of single-pulse discharge for CNTs production

The peak current and pulse duration have a significant effect on the production of CNTs. Figs. 4 and 5 show SEM (FEG-SEM, LEO Download English Version:

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